
Contents

Introduction	vii
About the Author	ix
1 Basic Idea of Photopolymerization	1
1.1 Introduction	1
1.2 Radical Polymerization	1
1.3 Monomers for Photopolymerization	7
1.4 Initiators of Photopolymerization	28
1.5 Inhibition of Polymerization	41
1.6 Cationic Photopolymerization	46
1.7 Photocrosslinking	50
1.8 Scission of Polymers	54
References	58
2 Chemically Amplified Resists	61
2.1 Introduction	61
2.2 Chemical Amplification of Photopolymers.....	61
2.3 Polymers for Chemical Amplification.....	65
2.4 Photoacid Generator	79
References	93
3 Process of Chemically Amplified Resists.....	97
3.1 Introduction	97
3.2 Progress of Resolution Limit	97
3.3 Immersion Lithography	103
3.4 Double Patterning	106
3.5 EUV Lithography	109
3.6 Direct Self-Assembly (DSA).....	115
References	118
4 Nanoimprint	121
4.1 Introduction	121
4.2 Thermal Nanoimprint	121
4.3 UV Nanoimprint	125
4.4 Cationic Polymerization of UV Nanoimprint.....	129
4.5 Ene-Thiol Polymerization of UV Nanoimprint.....	133
4.6 Soft Lithography.....	135
References	137

5 Industrial Application of Photopolymers	139
5.1 Introduction	139
5.2 Application to Electronics.....	139
5.3 Optical Adhesive Polymers	144
5.4 Holographic Photopolymers	152
5.5 Application to Medical Materials	159
5.6 Microelectromechanical Systems (MEMSs)	163
References	171
Index	175